

Cascade

CM300xi ULN

300 mm Semi-/ Fully-automated Probe System for Ultra Low Noise Measurements

Overview

FormFactor's CM300xi-ULN (Ultra Low Noise) is a revolutionary 300 mm wafer probing system designed for highly accurate flicker noise (1/f), random telegraph signal noise (RTN or RTS), and phase noise measurements of ultra-sensitive devices.

With the patented PureLine™ 3 technology, the ULN probing system eliminates 97% of the environmental noise experienced in previous probe systems, and establishes a new industry gold standard for ultra-low noise measurements.

When integrated with noise test equipment (flicker noise, RTN, phase noise), the CM300xi-ULN offers the industry's highest test throughput, using Contact Intelligence™ with motorized probe positioners, enabling fully Autonomous DC and low frequency noise probing with multi-DUT layouts for complete hands-free 24/7 operation.

Finally, the CM300xi-ULN takes the complexity out of low noise TestCell optimization. Just plug it in and go. Low-noise Site Survey and System Verifications significantly reduce setup costs and tool deployment time. This allows lab engineers to focus on getting good device data, that can be used to reduce the number of costly re-designs and accelerate time to market with lower development costs.



Industry-Firsts



PureLine™ 3 Technology

- First automated probe station to achieve **-190dB** spectral noise



Plug In and Go

- Integrated **TestCell Power Management** provides fully managed and filtered AC power to the entire system, prober and instruments



Autonomous 24/7 Operation

- Up to **4x** faster flicker noise thermal testing on **30 µm** pads



Reduce Setup Time and Costs

- Exclusive low noise **site survey**, and **system verification** services

Note: For physical dimensions and facility requirements, refer to the [CM300xi-ULN Facility Planning Guide](#).

Spectral Noise Floor			ULN On-Site Verification
Low band	1Hz – 1kHz	-120@1Hz, -140@10Hz, -160@100Hz (dBVrms/rtHz)*	●
Wide band	1kHz – 1MHz	≤-190 dBVrms/rtHz**	
Extended wide band	1kHz – 20MHz	≤-180 dBVrms/rtHz*	●

AC Noise

Chuck noise	≤ 3 mVp-p (≤ 2.5 GHz)***	●
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NOTE: All system noise performance results use test setup with triaxial thermal chuck, 50 Ω termination, multi-band high-quality LNAs, VSA or DSO instruments, with MicroChamber closed, station power ON, and thermal system ON. L-LNA (P/N 191-201), and H-LNA (P/N 191-101).

* ULN System Specification verified on-site during system installation using DSO instrument and L-LNA/H-LNA.

** Typical results using VSA and H-LNA instrument setup.

*** ULN System Specification verified on-site during system installation. Instrument setup: digital oscilloscope (DC to 2.5 GHz), 50 Ω input impedance, cable to chuck Triax connector using Triax to BNC (Guard-Shield Short) adapter. Measurement: Peak-Detect mode, Peak-Peak Noise Voltage (acquire 10sec data 64 times, calculate mean of Vp-p + Stdev of Vp-p)."

System Electrical Performance

Probe		CM300xi-ULN FemtoGuard (thermal)
Leakage*	Thermal Controller OFF	≤ 1 fA
	Thermal Controller ON	≤ 5 fA
Wafer Chuck		
Chuck leakage* (ATT)	Thermal Controller OFF	≤ 3 fA
	-55°C	≤ 6 fA
	-40°C	≤ 6 fA
	25°C	≤ 3 fA
	200°C	≤ 3 fA
	300°C	≤ 6 fA
Residual capacitance**		≤ 2.5 pF
Capacitance variation**		≤ 2 fF
Settling time***	All temperatures @ 10 V	≤ 50 fA @ 0.5 sec

* Overall leakage current is comprised of two distinctly separate components: 1) offset, and 2) noise. Offset is the DC value of current due to instrument voltage offset driving through isolation resistance. Noise is low-frequency ripple superimposed on top of offset and is due to disturbances in the probe station environment. Noise and leakage are measured with a B1500 with HR-SMU B1517 and the FormFactor program "DCN@10V" at defined test conditions.

** The residual (triaxial) chuck capacitance is measured with a B1500 with HR-SMU B1517 with the FormFactor program "Cap-Trx-3pA" at defined test conditions. This is chuck capacitance variation based upon chuck position anywhere in the 300 mm area, as measured by a stationary DC probe.

*** Settling time is measured with a B1500 with HR-SMU B1517 and the FormFactor program "ST_10V" at defined test conditions.

Note: Results measured with thermal chuck at standard probing height (20,500 μm) with chuck in a dry environment. Moisture in the chuck may degrade performance.

> Microchamber

Electrical

Integrated technologies	AttoGuard and PureLine (Generation 3)
EMI shielding	> 30 dB (typical) @ 1 kHz to 1 MHz

Light Shielding

Type	Complete dark enclosure around chuck
Wafer access	Front access door with rollout stage for easy manual wafer loading Side access door for fully automatic wafer loading
Probe compatibility	Standard MicroChamber TopHat™ allows access for up 8 probes Additional TopHat™ versions are available for special DC / RF probe configurations
Light attenuation	≥ 130 dB

Air-Purge Management¹

Purge	Clean dry air (CDA)
Purge Control	Automated flow control using dew point sensor.
Purge Flow	By default, the microchamber purge flow rate is automatically regulated to the lowest possible value required to ensure a frost-free environment. Experienced customers may also choose to control the CDA flow manually or via scripting (not recommended).
Typical Purge Flow Rates	80 l/min (2.8 SCFM) at chuck operating temperatures of -40°C to +300°C and during standby 100 l/min (3.5 scfm) at chuck operating temperatures below -40°C 240 l/min ² (8.5 scfm) (max. purge flow), temporarily for cooling down to temperatures below -40°C or during wafer loading and unloading

¹ See Facilities Planning Guide for detailed specification of facilities requirements.

² In case the max. purge flow is not made available, this might result in longer temperature transition times.

> Programmable Chuck Stage

	X-Y Stage	Z Stage	Theta Stage
Travel	301 mm x 501 mm (11.9 in. x 19.7 in.)	10 mm (0.4 in.)	± 3.75°
Resolution	0.2 µm (0.008 mils)	0.2 µm (0.008 mils)	0.2 µm (0.008 mils)*
Repeatability	≤ 1 µm (0.04 mils)	≤ 1 µm (0.04 mils)	≤ 1 µm (0.04 mils)*
Accuracy	≤ 2 µm (0.08 mils)	≤ 2 µm (0.08 mils)	≤ 2 µm (0.08 mils) ≤ 5 µm (0.2 mils) (Movements >2°)
Speed	50 mm/s (2 in./s)	20 mm/s (2 in./s)	
Lifting capacity (in excess of chuck)	-	20 kg (44 lbs.)	-
Probe-force deflection	-	≤ 0.0007 µm/µm slope per 10 kg load	-

*Measured at the edge of 300 mm chuck

> Platen System

Outer Platen

Dimensions	1058 mm (W) x 866 mm (D) x 25 mm (T)
Platen-to-chuck height	43.0 ± 0.5 mm (1.69 ± 0.02 in.)
Accessory mounting	Universal Rail System: 53 cm (21 in.) Left / Right Rail, 70 cm (28 in.) Rear Rail
Platen mount	Fixed height, High Thermal Stability kinematic mount
HTS Thermal Management	Integrated laminar-flow air-cooling for thermal expansion control

➤ Platen System (continued)

Inner Platen

Dimension	720 mm x 720 mm x 38 mm (incl. guard for fully-shielded version)
Weight	47 kg (104 lb.)
Material	Steel for magnetic positioners
Surface finish	Fine ground for vacuum positioner high stability

Platen Insert

Diameter	344 mm (13.5 in.)
Standard interfaces	TopHat™, probe card holders and IceShield™

Probe Card Holder*

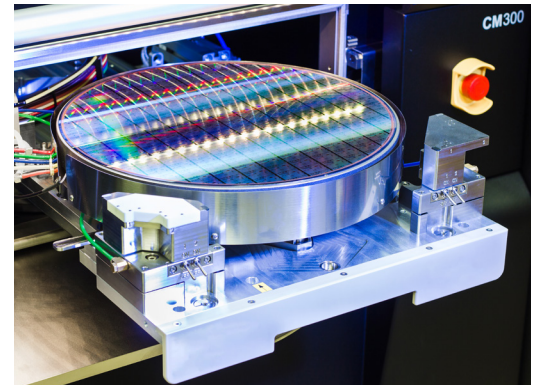
Probe card shape	Rectangular
Probe card width	114.5 mm (4.5 in.)
Max. probe card length (standard)	284 mm (11.18 in) /142 mm (5.59 in) from probe center to front/rear
Max. probe card length (HTS)	160 mm (6.30 in) / 80 mm (3.15 in) from probe center to front/rear
Tip drop**, (standard)	3.0 mm to 5.0 mm (0.12 in. to 0.20 in.)
Tip drop** (High Thermal Stability)	4.7 mm (0.185 in.)

* For more details, please see the Probe Station Accessory Catalog.

** Tip drop corresponds to the vertical distance between mounting level of probe card and needle tips. Field of view of ContactView (side view) camera within +/- 0.5 mm from nominal value (4.7 mm)

➤ Wafer Chuck

Diameter	305 mm (12 in.)
Material	Nickel- or gold-plated aluminum
DUT sizes supported	Shards (10 mm x 10 mm or SEMI-M1 compliant wafers up to 300 mm / 12 in.)
Vacuum rings	7 mm, 66 mm, 130 mm, 180 mm, 280 mm
Vacuum-ring actuation	Software controlled (Center, 200 mm, 300 mm)
Planarity incl. stage movement (with active z-profiling)	+/- 5 µm (0.2 mils)



➤ Aux Chuck

Left-side Aux Chuck	Ceramic vacuum chuck optimized for RF calibration Two 22 x 22 mm ² substrates Stop pins as alignment aid
Right-side Aux Chuck	Steel vacuum chuck optimized for cleaning Two 16 x 14.5 mm ² substrates, 38.1 x 38.1 mm ² area for self-adhering gel pad Stop pins as alignment aid
Planarity	+/- 5 µm, adjustable
Thermal isolation	Air gap, > 10 mm
Positional repeatability	2 µm (0.08 mils) after rollout event
Vacuum actuation	Independent manual vacuum switches

Active Vibration Isolation System

Attenuation*	0 dB @ 6Hz, 5 dB per octave @ 6Hz to 48Hz, 15 dB above 48Hz
Stage damping	15 dB in less than 1500 m sec

Sound level

Constant level	< 60 dB (A)
Peak level	< 72 dB (A)

* Please see facilities planning guide for minimum requirements concerning background vibrations.

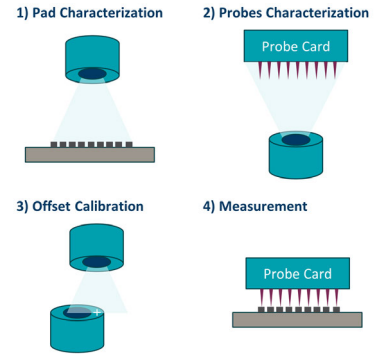
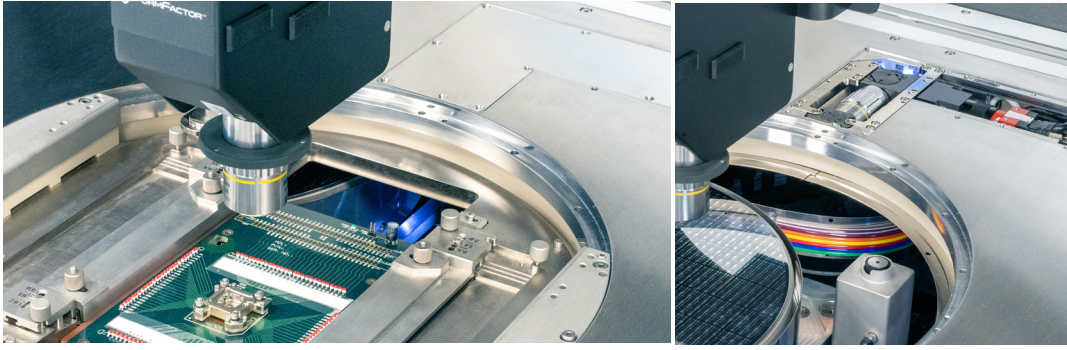
Communication Ports

Type	Qty	Location	Notes
USB 3.0	2	IPC front	For access to USB devices
GPIB IEEE 488.2	1	Rear connection panel	For test instrument control
USB 3.0	1	Front	For access to USB devices
USB 2.0	3	Font and rear	For connecting customer equipment
LAN	3	Rear connection panel	For connecting customer equipment and local network

Contact Intelligence Technology*

The CM300xi provides the lab automation capabilities needed to make critical precision electrical measurements. With Contact Intelligence technology, CM300xi adapts to temperature variance and provides automated drift correction for unattended testing on small pads over time and temperature. Contact Intelligence technology is enabled by the following features:

- VueTrack™ closed-loop positioning capability minimizes the need of manual re-adjustment when probing small pads across multiple temperatures.
- Velox probe station software provides a single command interface for automated temperature transitions continuously managing the separation between probes and pad during temperature ramp.
- Velox probe station software provides the ability to optimize the soak time after a temperature transition or when stepping across the wafer based on the temperature variance.
- ReAlign offers the capability to perform automated probe to pad alignment and unattended testing over temperature using probe cards that do not allow unlimited top microscope view of probes and pads.
- High Thermal Stability (HTS) microscope bridge enables automated over-temperature measurements.
- HTS platen provides stability over a wide thermal probing range.
- HTS probe card holder ensures EMI-shielded and light-tight environment, achieving accurate and reliable small-pad probing (option).
- As an additional option, motorized positioners allow automatic drift correction for each probe individually and facilitate unattended testing on small pads across multiple temperatures using Vuetrack Pro or Auto RF. Motorized positioners are part of the Autonomous DC and Autonomous RF Measurement Assistants.



The optional ReAlign™ feature offers the capability to perform “off-axis” probe to pad alignment (PTPA) independent from the main eVue microscope. ReAlign is the ideal tool for probe cards that do not allow viewing pads and probe tips from above. This is the case e.g. for vertical and Pyramid probe cards.

The ReAlign hardware includes two additional cameras: The downward looking “Platen Camera” is directly integrated into the platen of the CM300xi and is used for observation of the pads. The upward looking “ChuckView Camera” is used for characterization of the probe tips. The ReAlign wizard allows easy and fast setup with predefined algorithms for different probe cards like Pyramid, Apollo, T11, Cantilever, etc.

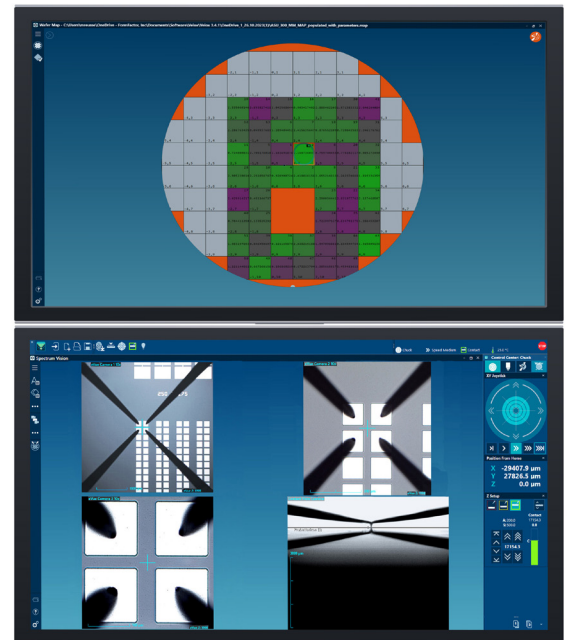
ReAlign can automatically manage temperature transitions without the need for operator intervention.

Hardware	Downward Looking Platen Camera, integrated into the Platen of the CM300xi
	Upward looking "ChuckView" camera. Mounted on chuck stage (independent from roll-out).
	"ContactView" camera for observation of wafer and probes from the side
Software	ReAlign software algorithm including ReAlign wizard

> Station Controller PC and Software

The CM300xi is equipped with a high-performance PC including Velox probe station control software and Windows 11 operating system.

Velox Probe Station Control Software	Velox software provides all features and benefits required for semi- and fully-automated operation of the probe system, such as:
	• User-centered design: Minimized training costs and enhanced efficiency. • Loader integration: No need for any additional software. Easy creation of workflows and receipts. • Smart automation features: Faster time to data due to reduced test cycle times. • Hundreds of tuneable options: High flexibility for a large variety of applications. • Simplified operation for inexperienced users: Reduced training costs with Workflow Guide and condensed graphical user interface. • Integrated Python Development Environment: Including Syntax Highlighting, AutoComplete, Debugger, Integrated Documentation. • Velox Integration Tool Kit: Enables integration of the prober into Customer Test Executives, supporting LabView, C++, C#, Visual Basic, MatLab. • Velox Interval Backup: Automated Backup with easy-to-use recovery function. Data is stored on a separate HDD drive.



Tester Interface	The CM300xi uses commands through GPIB as a permanent listener. The GPIB interface provides the ability to: • Request an inventory of all wafers available in the cassettes • Define a wafer map • Define a job (out of wafers and recipe) • Change chuck temperature and initiate re-alignment • Receive notifications when the wafer is aligned and ready to test
VeloxPro Package (Optional)	VeloxPro is a SEMI E95-compliant enhancement with test executive capabilities, featuring: • SEMI E95-compliant probe station control software with condensed graphical user interface for simplified operation • Test executive software enabling control of third-party measurement equipment via the probe station

➤ FemtoGuard® Chuck Performance

Electrical		Thermal Chuck				
		@ -55°C	@ -40°C	@ 25°C	@ 200°C	@ 300°C
Breakdown Voltage**	Force -to-Guard	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
	Guard-to-Shield	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
	Force -to-Shield	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V	≥ 500 V
Resistance***	Force -to-Guard	≥ 5 x 10 ¹² Ω	≥ 5 x 10 ¹² Ω	≥ 5 x 10 ¹² Ω	≥ 5 x 10 ¹¹ Ω	≥ 1 x 10 ¹¹ Ω
	Guard-to-Shield	≥ 5 x 10 ¹¹ Ω	≥ 5 x 10 ¹¹ Ω	≥ 5 x 10 ¹¹ Ω	≥ 5 x 10 ¹⁰ Ω	≥ 1 x 10 ¹⁰ Ω
	Force -to-Shield	≥ 5 x 10 ¹² Ω	≥ 5 x 10 ¹² Ω	≥ 5 x 10 ¹² Ω	≥ 5 x 10 ¹¹ Ω	≥ 1 x 10 ¹¹ Ω
Capacitance****	Force -to-Guard	≤ 1100 pF	≤ 1100 pF	≤ 1100 pF	≤ 1100 pF	≤ 1200 pF
	Guard-to-Shield	≤ 5000 pF	≤ 5000 pF	≤ 5000 pF	≤ 5000 pF	≤ 5000 pF

* Chuck performance measured inside test chamber at dew point < -70°C.

** Breakdown voltage tested at 500 V DC

*** The chuck resistance is measured in a dry environment. Moisture in the chuck may degrade performance. The chuck layer resistance is measured with a B1500 with HR SMU B1517, the FormFactor program "F-G_R_@10V@50Hz" at defined test conditions.

**** The chuck layer capacitance is measured with a B1500 with HR-SMU B1517, the FormFactor program "CAP_F-G-300pA" at defined test conditions.

➤ Thermal System Performance

ATT Thermal System

Model	TS-426-14E/R TS-416-14E/R	TS-426-08P/R	TS-416-02T	TS-416-05T
Components	Controller, Chiller	Controller, Chiller	Controller	Controller, Booster
Type	Air-cooled	Air-cooled	Air-cooled	Air-cooled
Temperature range	-60°C to 300°C	-40°C to 300°C	+30°C to 300°C	+20°C to 300°C
Temperature control	Pt100 (in Chuck)	Pt100 (in Chuck)	Pt100 (in Chuck)	Pt100 (in Chuck)
Resolution	0.1°C	0.1°C	0.1°C	0.1°C
Wafer temperature accuracy ^{1,2}	+/- 2.5°C	+/- 2.5°C	+/- 2.5°C	+/- 2.5°C
Thermal uniformity ³	1.0°C (0.3°C ⁶) @25°C 2.0 °C (1.2°C ⁶) @-60° 2.0°C (1.0°C ⁶) @200°C 3.0°C (2.0°C ⁶) @300°C	1.0°C @25°C 2.0°C @-40°C 2.0°C @200°C 3.0°C @300°C	1.0°C @30°C 2.0°C @200°C 3.0°C @300°C	1.0°C @25°C 2.0°C @200°C 3.0°C @300°C

ATT Thermal Transition Times⁴

Cooling				
25°C to -40°C	17 min 34 min (Eco ⁵)	59 min	-	-
25°C to -60°C	53 min	-	-	-
200°C to 25°C	18 min 27 min (Eco ⁵)	28 min	60 min (200°C to 30°C)	80 min (200°C to 25°C)
300°C to 25°C	33 min 44 min (Eco ⁵)	35 min	70 min (300°C to 30°C)	90 min (200°C to 25°C)
Heating				
-60°C to 25°C	7 min	-	-	-
-40°C to 25°C	5 min	5 min	-	-
25°C to 200°C	19 min	19 min	17 min (30°C to 200°C)	23 min
25°C to 300°C	35 min	35 min	33 min (30°C to 300°C)	39 min

¹ As measured with type-K thermocouple surface probe. Conditions: 12 mm diameter probe head, closed chamber with minimum recommended purge air, probe centered in probing area, on standard silicon wafer, and chuck at standard probe height. Typical type K thermocouple probe tolerances are $\pm 2.2^\circ\text{C}$ or $\pm 0.75\%$ of the measured temperature in $^\circ\text{C}$ (whichever is greater).

² The test setup can change the wafer temperature accuracy from the calibration by $\pm 5^\circ\text{C}$ (typical). Test setup attributes include open or closed chamber, probe or probe card construction and number of contacts, purge air flow rate, and lab environmental conditions.

³ Peak-to-peak temperature measurement variation across probing sites.

⁴ Typical values, facilities media according to requirements as defined in the Facility Planning Guide.

⁵ Eco mode limits the CDA consumption of the chuck to max. 315 l/min

➤ Microscope Bridge/Transports

Programmable Bridge/Transport Specifications, High-Temperature Stability*

Travel	75 mm (X) x 75 mm (Y) x 150 mm (Z) (3.0 in. x 3.0 in. x 5.9 in.)
Travel in TopHat	26 mm x 26 mm (1 in. x 1 in.)
Z Lift	150 mm (5.9 in.)
Resolution, X-Y axis	1 μm (0.04 mils)
Resolution, Z axis	0.4 μm (0.016 mils)
Repeatability, X-Y axis	$\leq 2 \mu\text{m}$ (0.08mils)
Repeatability, Z axis	$\leq 1 \mu\text{m}$ (0.04mils)
Accuracy, X-Y axis	$\leq 5 \mu\text{m}$ (0.2 mils)
Accuracy, Z axis	$\leq 4 \mu\text{m}$ (0.016 mils)
Speed	5 mm/sec (0.2 in./sec)

Standard and Optional Features

		CM300xi-ULN
Base	Fully-shielded probe station platform, with MicroChamber, AttoGuard and PureLine 3 technologies	●
	Programmable XYZ Theta Chuck stage (ULN)	●
	Velox PC (Windows 11) with dual 27-inch monitor mounted on an ergonomical arm	●
	ContactView™ (side view camera) in East-West direction (ULN)	◐
	IntelliControl, including Airgun and Vacuum connection at front, additional LAN and USB ports at rear side	●
	Active Vibration Dampening System	●
	GPiB interface	●
Power Conditioning Unit	Half Rack Size ¹ including EMO Master Unit and Filter Module with 4 additional Power Outlets	●
	Full Rack Size ¹ including EMO Master Unit and Filter Module with 4 additional Power Outlets	●
	Additional Filter Modules with 6 power outlets for customer test instruments	○
Microscope Transport	Programmable HTS Microscope Bridge 75 mm x 75 mm	◐
Platen Inserts	EMI- and light-tight shielding with TopHat, AttoGuard technology for accurate IV/CV measurements (ULN)	●
	Probe card holder	○
	4-sided RF-TopHat for RPP positioners and probe arms with inclined angle	○
User Interface Options	Velox Dash, tablet with Velox companion app, keyboard, mouse	◐
	Classic user interface with joystick, keyboard and mouse	○
	3D Manual Controls, including XY knobs and Virtual Platen Lift for intuitive, rapid and precise manual control of the stage in X, Y and Z direction	○
Automation Options	Semi-automated configuration	◐
	Fully-automated configuration for operation with MHU301	○
	VueTrack on-axis probe-to-pad alignment solution	◐
	ReAlign off-axis probe-to-pad alignment solution for opaque/vertical probe cards	○
Non-Thermal Chucks²	FemtoGuard triaxial chuck, non-thermal	○
	FemtoGuard triaxial chuck, non-thermal, with lift pins for fully-automated operation with MHU301	○
Thermal Chucks²	FemtoGuard triaxial chuck, thermal, -60°C to 300°C (ATT)	◐
	FemtoGuard triaxial chuck, thermal, -60°C to 300°C (ATT), with lift pins for fully-automated operation with MHU301	○
Chuck Benefits	Chuck mounted on roll-out stage for convenient and safe manual loading of wafers from the front	●
	Aux Chuck Kit including CAL chuck (left) and CLEAN chuck (right)	●
Custom Adaptions	Customer specific adaptations are available upon request	○

¹ Customer can choose either half rack or full rack size

² All chucks are available with either nickel or gold plating. Thermal Chucks require a thermal system for operation at a controlled temperature.

● Always included ◐ Default configuration ○ Option

Thermal Systems

Part Number	General Description	
TS-426-14E	Thermal System, -60°C to 300°C, ATT (220-240 VAC 50 Hz), CDA-saving, requires CDA dew point <-80°C	○
TS-426-14R	Thermal System, -60°C to 300°C, ATT (200-220 VAC 60 Hz, 200 VAC 50 Hz), CDA-saving, requires CDA dew point <-80°C	○
TS-416-14E	Thermal System, -60°C to 300°C, ATT (220-240 VAC 50 Hz), with air dryer	○
TS-416-14R	Thermal System, -60°C to 300°C, ATT (200-220 VAC 60 Hz, 200 VAC 50 Hz), with air dryer	○
TS-426-08P	Thermal System, -40°C to 300°C, ATT (200-230 VAC 50/60 Hz), CDA-saving, requires CDA dew point <-70°C	○
TS-426-08R	Thermal System, -40°C to 300°C, ATT (200-220 VAC 60 Hz), CDA-saving, requires CDA dew point <-70°C, UL-certified	○
TS-416-05T	Thermal System, +20 to 300°C, ATT (100-230 VAC 50/60Hz)	○
TS-416-02T	Thermal System, +30 to 300°C, ATT (100-230 VAC 50/60Hz)	○

Note: Thermal systems must match the thermal chuck selected, i.e. TS-416-xxx and TS-426-xxx thermal systems are compatible with TC-426-xxx chucks. The upper temperature limit is defined by the chuck.

○ Option

Semi-Automated

CM300xi-ULN probe system



Fully-Automated

CM300xi-ULN with MHU301 (In this example the CM300xi is configured on the right side of the MHU301).



➤ Wafer Loader MHU301

Material handling unit	The MHU301 is a wafer loader that provides the ability to fully automate the operation of your CM300xi-ULN, offering a high level of efficiency and precision. The MHU301 is equipped with a SEMI standard load port and is capable of processing 300 mm FOUP/FOSB cassettes or, optionally, also 200 mm open cassettes. It should be noted that manual loading of wafers and wafer fragments is still possible by bypassing the MHU301 using the chuck roll-out stage on the front of the probe station.
Wafer Cassettes	SEMI-compliant FOUP/FOSB (SEMI E47.1 , SEMI M31)
Wafers	SEMI M1 compliant

Standard and Optional Features	MHU301
Prober Orientation - single configuration with one CM300xi either on left or right side of the MHU	●
SEMI-compliant Load Port for 300 mm FOUP/FOSB cassettes	●
Prealigner	●
Horseshoe End Effector for 200 mm and 300 mm wafers	●
RFID Reader for RFID tags on 300 mm wafer cassettes	○
Adapter for use of open 200 mm Wafer Cassettes	○
Adapter for use of open 200 mm Wafer Cassettes, including RFID reader for 200 mm cassettes	○
Optical Wafer ID Reader for reading optical codes ¹ on top and back side of wafer	○
Optical Wafer ID Reader for reading optical codes ¹ on top side of wafer	○
Optical Wafer ID Reader for reading optical codes ¹ on back side of wafer	○
Fan Filter Unit for reducing dust pollution level inside MHU	○
Quick Access Port: Additional temporary storage slot inside MHU for 2 wafers	○
Seismic restraint kit	○

¹ OCR: Semi-Font (SEMI M12, M13 or SEMI M1.15), Triple, OCR-A, IBM, Chartered fonts; 2D: T7 Data Matrix (SEMI M1.15), Data Matrix, QR Code; Barcodes: BC 412 (SEMI T1-95), IBM 412

● Always included ○ Option

➤ System Throughput

Semi-automated system

Chuck stepping time	≤ 0.75 sec (200 μm Z down – 1000 μm X-Y – 200 μm Z up)
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Fully-automated system¹

FOUP cassette load	≤ 30 sec (incl. wafer scan)
Wafer handling cycles @ ambient	≤ 1.3 min (Cassette → PreAligner → Prober → Cassette) ≤ 1.6 min (Cassette → PreAligner → IDReader ¹ → PreAligner → Prober → Cassette) < 1 min (Wafer 1: Prober → Cassette; Wafer 2: Quick Access Port ² → Prober)

¹ Tested on Entegris F300 Autopod

² Optional

➤ Regulatory Compliance

Certification	CE declared, 3rd party tested for CB against IEC 61010 including National Standard CSA C22.2 No. 61010-1-12 / UL 61010-1:2012, certified for US and Canada (cNRTLus), SEMI S2 and S8.
	Copies of certificates are available on request.

➤ Warranty

Warranty*	Fifteen months from date of delivery or twelve months from date of installation
Service contracts	Single- and multi-year programs available to suit your needs

* See FormFactor's Terms and Conditions of Sale for more details.

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